

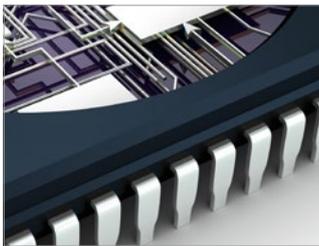


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PALLUNA[®] 452

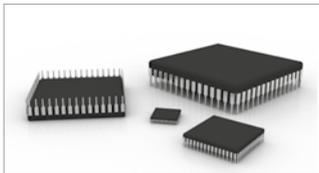
PALLADIUM ELECTROLYTE



Pure palladium electrolyte with excellent bonding and solderability

PALLUNA[®] 452 is a weakly ammoniacal electrolyte for the deposition of palladium in continuous systems and rack plating. It is used especially where excellent bondability and solderability are required.

The electrolyte has already been used for years in semiconductor technology and is mainly used in selective high-speed deposition. It is particularly suitable for systems with immersion cells, belt cells, brush cells, jet and spot systems.



Advantages

- Excellent bonding and solderability
- High deposition rate
- Simple electrolyte feed
- For continuous lines and rack plating

Applications

- Lead frames

PALLUNA[®] 452

PALLADIUM ELECTROLYTE

TECHNICAL SPECIFICATIONS

Electrolyte characteristics		Coating characteristics	
Electrolyte type	weakly ammoniacal	Coating	Pure palladium
Metal content	3 (2.5 - 7) g/l Pd	Purity of deposit	99.9 wt.% Pd
pH value	8.0 (7.5 - 8.4)	Color of deposit	white
Temperature	55 (50 - 60) °C	Brightness	matt
Current density range (depending on equipment)	1 - 2 A/dm ²	Max. coating thickness	approx. 0.3 µm
Plating speed	ca. 0.25 µm/min bei 1 A/dm ² ca. 0.50 µm/min bei 2 A/dm ²	Density	approx. 12 g/cm ³
Anode material	PLATINODE [®] 167		

YOUR CONTACT

Do you have a specific question or would you like a no-obligation quote calculation?
Our specialist will be happy to help you with any technical questions you might have.



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